Event: SPIE LASE: Lasers and Applications in Science and Engineering, 2009, San Jose, California, United States
Commercial and Biomedical Applications of Ultrafast Lasers IX

Joseph Neev
Stefan Nolte
Alexander Heisterkamp
Rick P. Trebino
Editors

25–28 January 2009
San Jose, California, United States

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SPIE

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IMRA America, Inc. (United States)

Published by
SPIE

Volume 7203
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